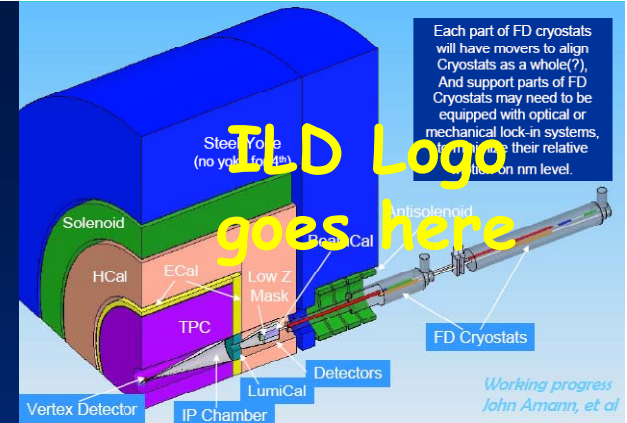
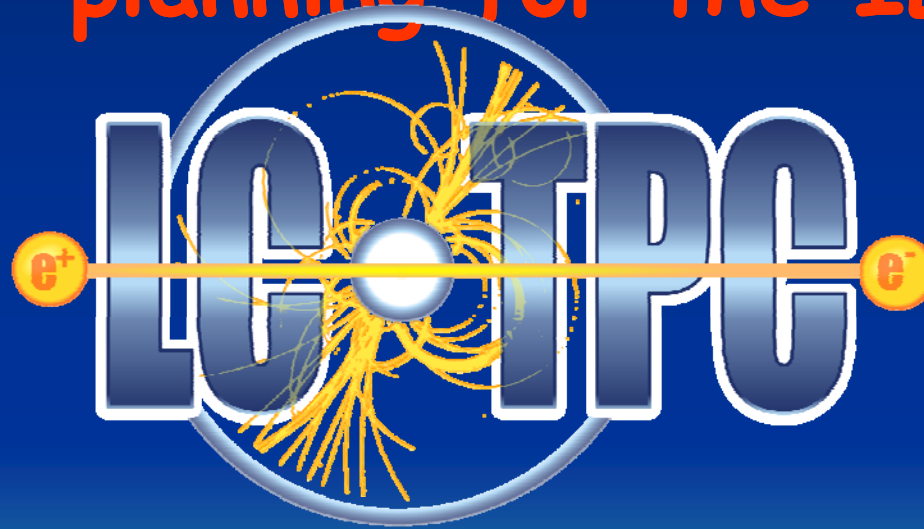


Worldwide Study of
the Physics and Detectors

for Future Linear
 e^+e^- Colliders



Continuation of LCTPC "advanced-endcap" planning for the ILD LOI



Ron Settles MPI-Munich
LCTPC advanced-endcap studies for
the LOI

10 Nov. 2008

LCTPC engineering model for LOI

- "Advanced endplate" meetings now continuing to understand the electronic density that will allow building a coolable, stiff, thin endplate. There were three meetings in 2007.
- The proposal for next steps (email 31.10.2008):

Reverse order today {

DAQ issues added

- CERN 10 Nov. 14:00 (room to be announced):
 - I will give an overview of the issues.
 - Alain Herve will review the cooling strategy for all subdetectors, boundary conditions for the gas and how some of the CMS subdetectors are cooled.
 - Luciano will review the ideas he showed at Paris/2007 and maybe come up with first ones for the power pulsing.
 - AOB
- LCWS 15-20 Nov (day, room to be announced):
 - Summary the CERN 10 Nov. meeting.
 - Dan has been interested in the LCTPC endcap material/layout and will show some ideas.
 - Jan will tell us some pixel thoughts how an endcap for a large pixel TPC might look.
 - AOB
- Meeting somewhere in Europe in Jan.2009 (time, place to be announced)
Organized by Takeshi and possibly involving experts from other technologies.
- ILD Korea Feb. 2009:
 - Review the previous three meetings above.
 - Depending who goes to Korea, iterate on respective issues.
 - Come up with a "to-do" list of things to be covered at the final meeting before the LOI, namely at the
- TIPP meeting on 11 March 2009
 - This agenda can be made up depending on the outcome of the above and should envisage an iteration on critical topics.
 - Finally conclude what should go into the LOI about the lctpc (advanced) endcap.

10 Nov. 2008

LCTPC engineering model for LOI

- Endplate, electronics, power
- This is about “standard” electronics (CMOS pixel-electronics require a separate study).
- “Advanced endplate” meetings now continuing to understand the electronic density that will allow building a coolable, stiff, thin endplate.
- The (sometimes self-contradicting) requirements:
 - Number of pads: as many as possible
(
 - Power to cool: as small as possible
(
(
 - Endplate material: as stiff and as thin (X_0) as possible
(

LCTPC engineering model for LOI

- Endplate, electronics, power
- This is about “standard” electronics (CMOS pixel-electronics require a separate study).
- “Advanced endplate” meetings now continuing to understand the electronic density that will allow building a coolable, stiff, thin endplate.
- The (sometimes self-contradicting) requirements:
 - Number of pads: as many as possible (~10⁶ channels per endcap?)
 - Power to cool: as small as possible (0.5mW/channel with power pulsing?) (cooling medium liquid or gas?)
 - Endplate material: as stiff and as thin (X₀) as possible (purpose of the present exercise)

LCTPC performance: 3-slides-overview from Cambridge ILD-LOI meeting

- continuous 3-D tracking, easy pattern recognition throughout large volume
- ~98-99% tracking efficiency in presence of backgrounds
- time stamping to 2 ns together with inner silicon layer
- minimum of X₀ inside Ecal (~3% barrel, ~15% endcaps)
- $\sigma_{pt} \sim 50 \oplus \text{diff} \mu\text{m} (r\phi)$ and $\sim 500 \mu\text{m} (rz)$ @ 4T
- 2-track resolution <2mm (r ϕ) and <5mm (rz)
- dE/dx resolution <5% -> e/pi separation, e.g.
- design for full precision/efficiency at 10 x estimated backgrounds

1) As a function of drift-distance L_{drift} , the expression for the $r\phi$ point resolution is, as you know,

$$\sigma_{point}^2 = \sigma_0^2 + C_d^2 / N_{eff} * L_{drift}$$

Proposal 1) on point resolution:

$$\sigma_0^2 = (50\text{micron})^2 + (900\text{micron} * \sin(\text{phi}))^2$$

(where phi is the local azimuthal angle of track wrt the padrow)

$$C_d^2 / N_{eff} = 2.5^2 * (22 \sin(\text{theta}) * h / 6\text{mm}) = (5.3 \text{micron} / \sqrt{\text{cm}})^2 * (6\text{mm} / h) * \sin(\text{theta})$$

(this is for B=4T which we favor, h is the pad height=pad-row pitch in mm, theta is the polar angle)

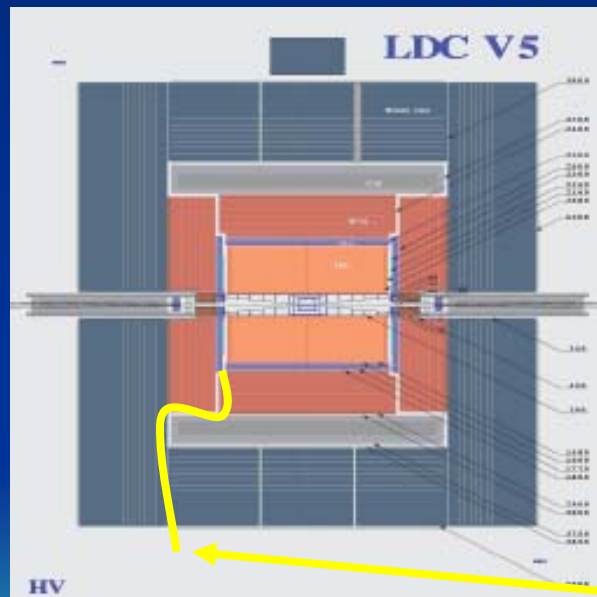
$$\sigma_{z(x)} = \sqrt{(400\text{micron})^2 + z(\text{cm}) * (80\text{micron} / \sqrt{\text{cm}})^2}$$

LCTPC engineering model for LOI

- Size, weight, support, dead areas

- Dead areas:

- 10 cm in z at each endcap for "standard" electronics/cables (may be increased later)



2) Endplate thickness:

Proposal 2) on Endplate thickness:

$$\Rightarrow X_{\text{(tpcendplate)}}/X_0 = 0.15$$

New Mokka list (** mark changes wrt old list):

dz (mm)	material	% X ₀
0.003	copper	0.02 gating
0.03	kapton	0.01
0.003	copper	0.02
1.964	TPC_gas	0.002
0.003	copper	0.02 mpgd
0.03	kapton	0.01
0.003	copper	0.02
1.964	TPC_gas	0.002
0.003	copper	0.02 mpgd
0.03	kapton	0.01
0.003	copper	0.02
3.964	TPC_gas	0.004
0.05	copper	0.35 pads
2	g10	1.03
0.5	silicon_2.33g/cm	0.53 ROelectr
2	epoxy,etc	1.932
1	kapton	0.35
**2	aluminium	2.24 cooling
1	kapton	0.35
**3	carbonfibre	1.59 stiffness
80.45	Air(0.85)+G10(0.15)	0.02 air+
		+6.22 g10 space:ROboards
summa (new model)		
100mm		14.77 %X ₀

- Space needed for $\varphi \approx 1\text{cm}^2$ -cables here
 $\sim 10^3$ cables/side thru 5cm rings $\approx 1\text{m}^2$ /side

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LCTPC advanced-endcap studies for the LOI

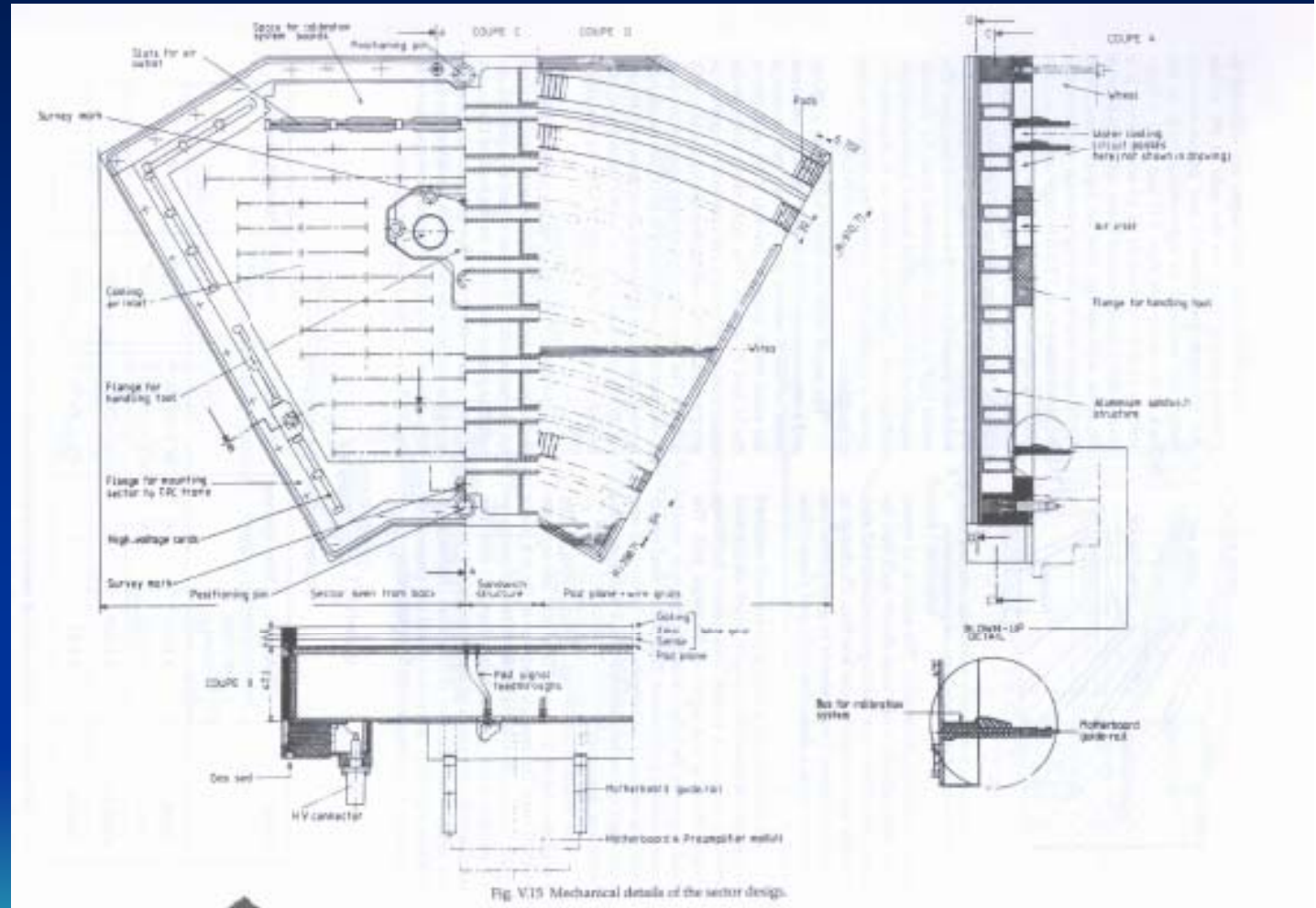
LCTPC engineering model for LOI

- Endplate, electronics, power
- Endplate material on preceding slide: *GOAL ~ 15% X₀*
- With 0.5mW/channel with power pulsing, estimated by a EUDET development of a generalize TPC RO chip based on a further development of the Alice Pasa/Altro \Rightarrow 0.5kW/endcap (*Luciano report*)
- Cooling (liquid or gas) under study (*Alain report*)
- DAQ issues (*Xavier report*)
- Mechanical structure (*next meeting at LCWS2008*)

LCTPC engineering model for LOI

- Endplate: how was it done in Aleph?

- Sandwich structure for stiffness
- 22000 channels, 1.3kW per endcap
- Air/water cooling
- 25% X₀ without cables



LCTPC engineering model for LOI

- Endplate, electronics, power
- Endplate material: *GOAL ~ 15% X₀*
- Mechanical structure (*next meeting at LCWS2008*)
 - Aleph concept no longer possible for LCTPC
 - What can we do if electronic density too high?
 - Reduce # of channels

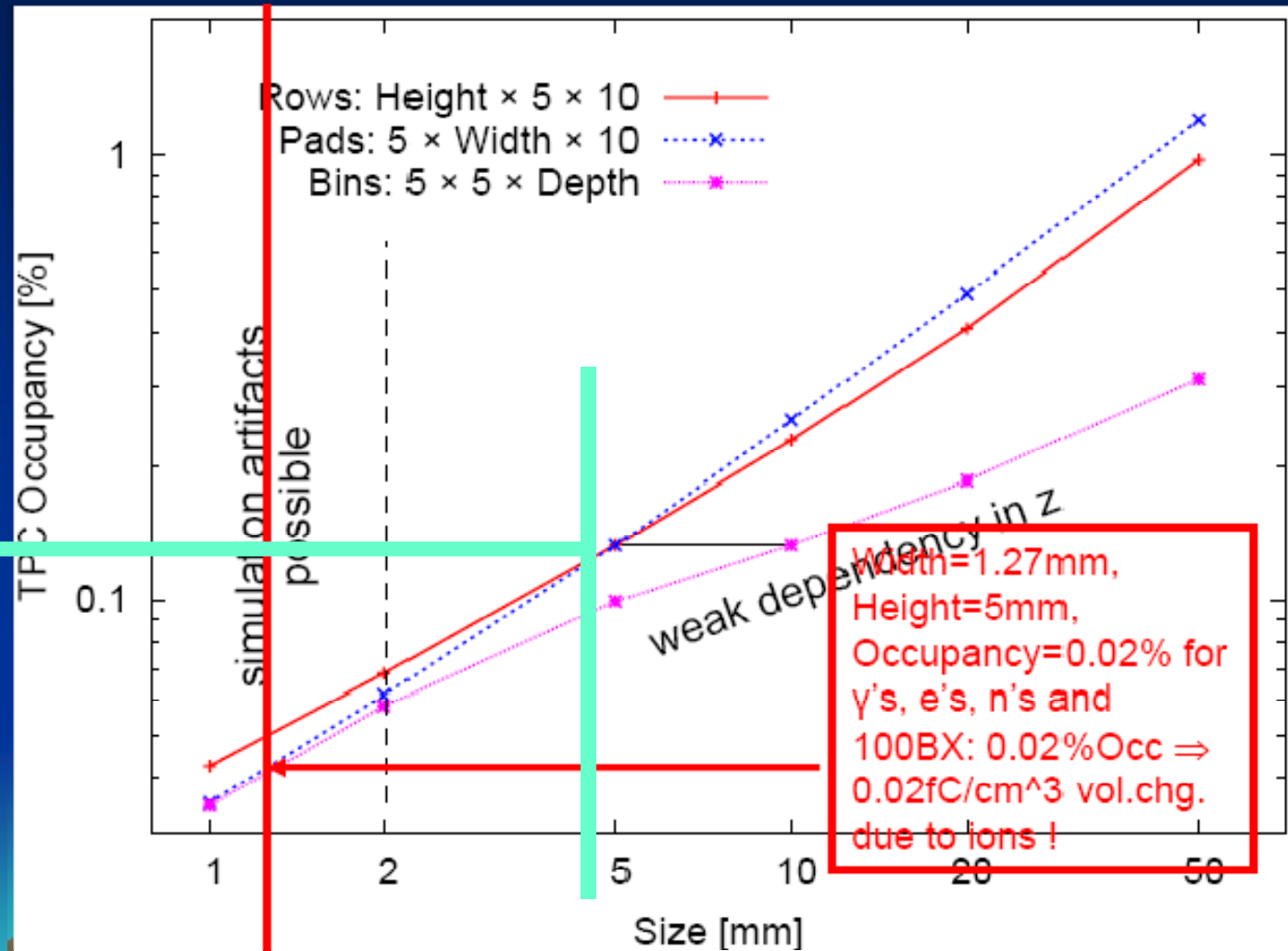
Gluckstern: $\delta(1/p)$ indep. of pad height
when σ_{pt} diffusion dominated

Price you pay is...

2. LCTPC sensitivity to backgrounds

See talk#3 in opening session at Cambridge by Adrian Vogel:

Higher occupancy



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LCTPC advanced-endcap studies for
the LOI

LCTPC engineering model for LOI

- Endplate, electronics, power
- Endplate material: *GOAL ~ 15% X₀*
- Mechanical structure (*next meeting at LCWS2008*)

Continued next meeting...

Back-up slides

10 Nov. 2008

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the LOI

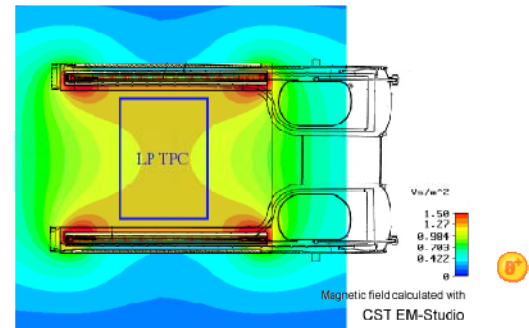
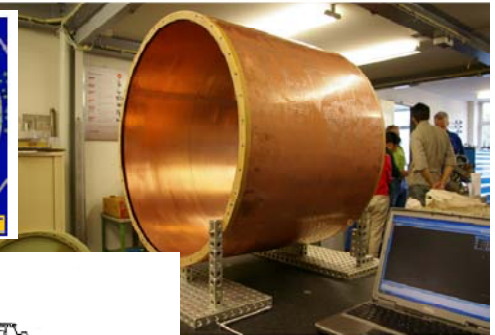
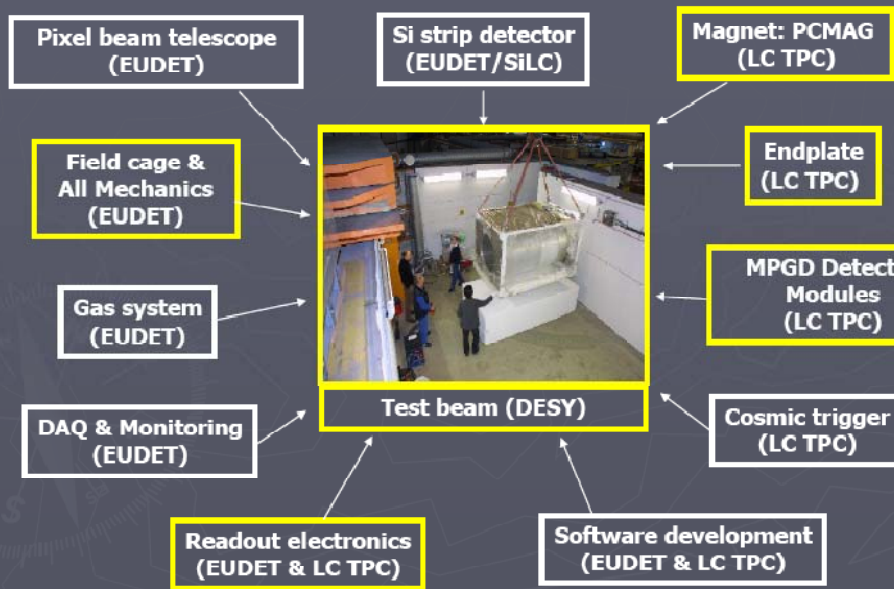
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LCTPC performance goals

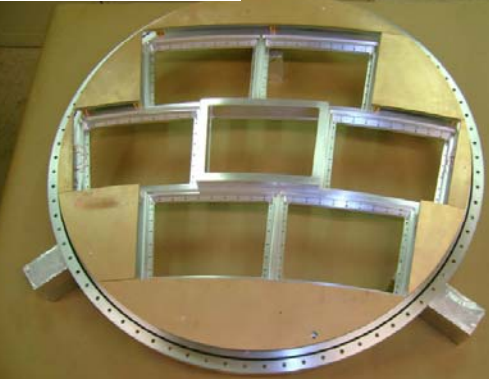
- R&D plans/risks

...to be verified (or revised) after tests on the Large Prototype:

Consolidation Phase TPC Large Prototype Beam Test at DESY



infrastructure for TPC R&D, available for many researcher groups



10 Nov. 2008

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LCTPC advanced-endcap studies for the LOI

LCTPC MOA to R&D/design a TPC: Status August 2008

Americas

BNL ✓
Carleton ✓
Montreal req
Victoria ✓
Triumf ✓
Cornell ✓
Indiana ✓
LBNL prom
Louisiana Tech req

Observer groups

Iowa State
MIT
Purdue
Yale
TU Munich
UMM Krakow
Bucharest

Asia

Tsinghua ✓
CDC:
Hiroshima req
KEK ✓
JAX Kanagawa req
Kinki U ✓
Nagasaki InstAS req
Saga ✓
Kogakuin ✓
Tokyo UA&T req
U Tokyo req
Minadano SU-IIT req

Signatures 24

Promised 3

Requested 11

New groups welcome

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LCTPC advanced-endcap studies for
the LOI

Europe

Brussels ✓
LAL Orsay req
IPN Orsay req
CEA Saclay ✓
Aachen ✓
Bonn ✓
DESY ✓
EUDET ✓
U Hamburg ✓
Freiburg req
Karlsruhe req
MPI-Munich ✓
Rostock ✓
Siegen prom
NIKHEF ✓
Novosibirsk ✓
St. Petersburg prom
Lund ✓
CERN ✓

LCTPC engineering model for LOI and simulation

- Fieldcage, chamber gas
- Based on experience (Aleph, Star, Alice) and recent fieldcage for the LP:



we estimate $\sim 3\text{-}4\%$ X_0 total for the inner and outer fieldcages.

- Gas properties have been rather well understood by our many small-prototype R&D tests. The choice for the LCTPC will be a BIG issue which would require a long discussion for which there is no time here. This has no effect on the simulation. For the engineering, the boundary condition is that we must use a non-flammable gas.

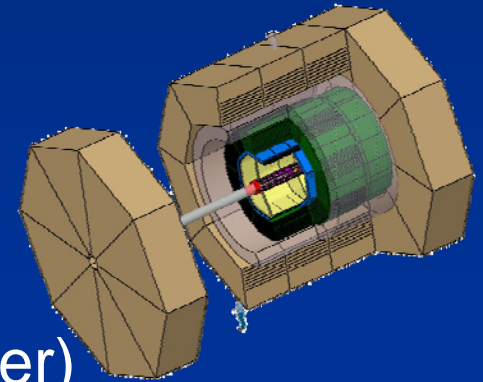
5. Push-pull ability

- At start, guess need 1/pb Z-peak calibration after each push-pull.
- This can probably be relaxed as experience is gained.
- Preliminary hardware discussion at IRENG07, SLAC Sept. 07:

Services Detector ↔ Trailer

TPC :

- 500 W per end plate
- HV/service/data cables: $\sim 10^3$ per side
- Gas/cooling supply
- Alignment laser
- 50-200kW racks in the counting house (trailer)



Considerations on readout plane Luciano's talk @ Paris Eudet mtg

IC Area (die size)

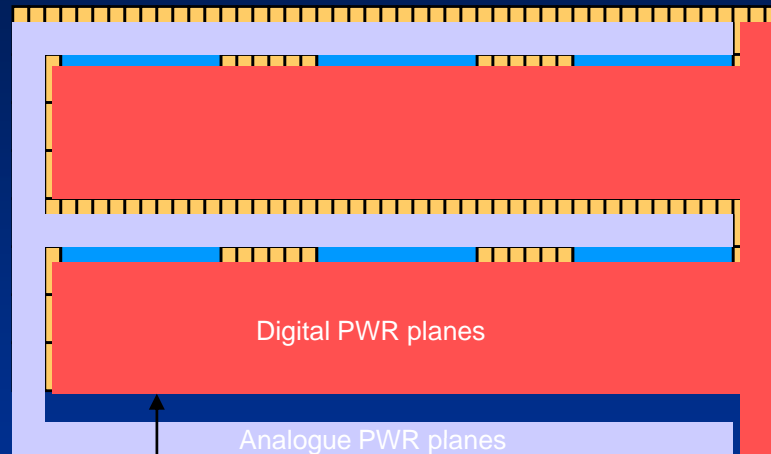
- 1-2 mm² /channel
 - Shaping amplifier 0.2 mm²
 - ADC 0.6 mm² (estimate)
 - Digital processor 0.6 mm² (estimate)
- in the following we consider the case of 1.5mm² / channel
- 64 ch / chip ➔ ~ 100 mm²

Area of the chip on the PCB: 14 x 14 mm² / chip \Rightarrow ~ 3 mm² / pad

PCB dimensions < 40 x 40 cm² \Rightarrow ~53000 pads, ~800 FE chips / board

Considerations on readout plane

PCB topology and layer stack-up

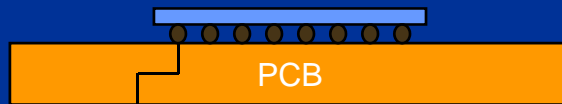


vdd
Digital signals II
gnd
Digital signals I
gnd
det gnd
Pad signals routing
Pad layer

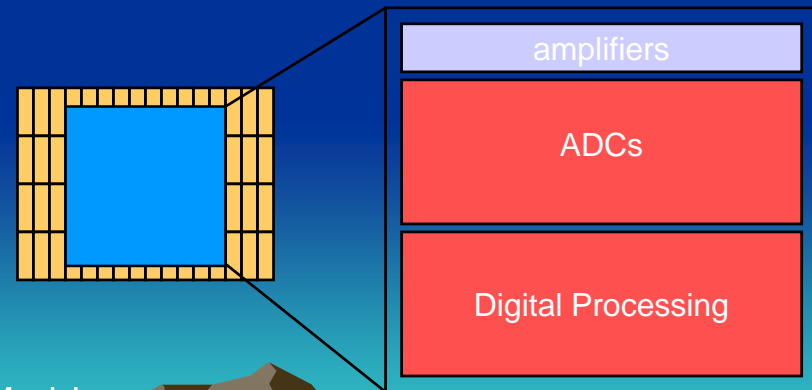
8-layer PCB



Flip-chip mounted



Chip floorplan



Considerations on readout plane

Power consumption

- amplifier 8 mW / channel
- ADC 30 mW / channel
- Digital Proc 4 mW / channel
- Power regulation and links 10 mW / channel
- duty cycle: 1%
- average power / channel ~ 0.5 mW / channel
- average power / m² 167 W